

2009 SYMPOSIUM TECHNICAL PROGRAM UPDATE

Withdrawn Oral Papers

- 7.1:** *Invited Paper:* Analysis for Reduction of Power Consumption in PDPs
B. H. Lee, *Samsung SDI Co., Ltd., Chungcheongnam-do, Korea*
- 28.3:** Pixel Parasitic Capacitance Modification with Embedded Gate Driver on Panel for a-Si High-Resolution Technology Scheme
J-C. Peng, *InnoLux Display Corp., Miao-Li, Taiwan*
- 33.2:** A Novel Driving Method for Cost-Competitive a-Si TFT-LCDs
S-H. Moon, *LG Display Co., Ltd., Kyunggi-do, Korea*
- 36.3:** Analysis of Depolarized Light Scattering in LCD Panel and Proposal of LCD Systems for Enhancing Contrast Ratio
H. Takemoto, *Nitto Denko Corp., Hiroshima, Japan*
- 49.2:** Application of Multi-Tone Mask Technology in Photolithographic Fabrication of Color-Filter Components in LCD
T. Sai, *Mitsubishi Chemical Corp., Yokohama, Japan*
- 51.3:** Use of Transparent Conductive Polymer for Electrode Materials in Flexible Electronic Paper
M. Nishii, *Bridgestone Corp., Tokyo, Japan*
- 56.4:** Formation of Single-Layered Al-Alloy Interconnection for Source and Drain of a-Si TFT Using One Wet- and One Dry-Etching Process for a Four-Mask Process
H. Goto, *Kobe Steel, Ltd., Kobe, Japan*
- 58.4:** *Invited Paper:* Solution Assembly of Transistor Arrays Based on Sorted Nanotube Networks for Large-scale Flexible Electronic Applications
Z. Bao, *Stanford University, Palo Alto, CA, U.S.A.*
- 63.4L:** *Late-News Poster:* Impact of Glass Substrate and Frit Properties on Sealing
L. Zhang, *Corning Incorporated, Corning, NY, U.S.A.*
- 68.1:** *Invited Paper:* Design Scheme of LED Scanning Backlights for Field-Sequential-Color LCDs
K. Sekiya, *Research Institute for Advanced Liquid Crystal Technology, Aomori, Japan*
- 68.2:** Novel Laser-Light-Source Backlight for LCDs
F-W. Ren, *Foxconn, Shenzhen, China*

2009 SYMPOSIUM TECHNICAL PROGRAM UPDATE

Withdrawn Poster Papers

- P.13:** Low-Temperature Aluminum Indium Oxide TFTs Using a Sol-Gel Process
B-S. Bae, *KAIST, Daejeon, Korea*
- P.23:** High-On-Current a-IGZO TFT
S. Chang, *KIST, Seoul, Korea*
- P.47:** Hold-Type-Display Motion-Blur Reduction with Spatial Compensation
S.-T. Cho, *InnoLux Display Corp., Miao-Li County, Taiwan*
- P.64:** New Drying Process without Pin-Mura for Ink-Jet Alignment Layer Printing of Large-Sized LCDs
C. H. Tai, *AU Optronics Corp., Hsinchu, Taiwan*
- P.90:** Photoluminescence of Barium Magnesium Pyrophosphate Co-Doped with Eu^{2+} and Mn^{2+} Ions
H-K. Jung, *Korea Research Institute of Chemical Technology, Daejeon, Korea*
- P.97:** Improvements in the Screen Filter Design of PDPs by Modifying the EMI Shielding Effectiveness
H-C. Kim, *LG Electronics, Inc., Seoul, Korea*
- P.100:** Effects of Acetone for Photosensitive Carbon-Nanotube Paste
J-W. Yu, *Korea University, Seoul, Korea*
- P.121:** EMD2 (Electro-Magnetic Digital Display) Technology: A New Bi-Stable Ultra-Low-Power Reflective-Display Technology for Outdoor Signage and Large-Area Displays
C. Edwards, *Tred Displays Corp., Albuquerque, NM, U.S.A.*
- P.181L:** **Late-News Poster:** High Performance of P-channel SiOG TFT
J. Jang, *Kyung Hee University, Seoul, Korea*
- P.192L:** **Late-News Poster:** Novel High-Voltage Address Driver (Hi-AD) IC for High-Performance PDPs with Single Sustain Drive
T. Nagase, *Hitachi Ltd., Ibaraki, Japan*